Section II. (REMARKS)

The claims pending herein are 1-2, 4-15, 17-23, 53-57, and 59.

Allowable Subject Matter

In the November 24, 2006 Office Action, the Examiner objected to part A¹ of claim 7 and claim 57 as being dependent upon a rejected base claim and indicated that they would be found allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

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Applicants acknowledge same.

<u>Provisional Double Patenting Rejection Under the Judicially Created Doctrine of</u> <u>Obviousness-Type Double Patenting</u>

In the November 24, 2006 Office Action, the Examiner provisionally rejected claims 8-9, 11-13, 22, 37-38, 40-42 and 51 under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 1-7, 9-17, 21-22, and 33-48 of co-pending U.S. Patent Application No. 10/389,214. Applicants acknowledge same.

According to MPEP 804 (I)(B)(1):

"If the [obviousness-type double patenting] rejection is the only rejection remaining in the later-filed application, while the earlier-filed application is rejectable on other grounds, a terminal disclaimer must be required in the later-filed application before the rejection can be withdrawn."

It is noted that the earlier co-pending application, U.S. Patent Application No. 10/389,214, which presently pending claims 8-9, 11-13, 22, 37-38, 40-42 and 51 are provisionally rejected under, is still pending.

If in the future, co-pending U.S. Patent Application No. 10/389,214 remains rejectable on other

¹ according to the Examiner, part A corresponds to the elected Formula G subspecies.

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grounds, the obviousness-type double patenting rejection is the only rejection remaining to the presently pending case AND the presently pending claims are an obvious variation of the invention defined in claims 1-7, 9-17, 21-22, and 33-48 of co-pending U.S. Patent Application No. 10/389,214 (which can only be objectively assessed when the only rejection remaining in the presently pending case is the obviousness-type double patenting rejection), applicants will submit the required terminal disclaimer.

Evidence Required to Establish Common Ownership

Applicants hereby declare and affirm that U.S. Patent Application Publication No. 2004/0180300, filed on March 14, 2003 in the name of Minsek et al., claiming priority to U.S. Provisional Patent Application No. 60/434,971 filed on December 20, 2002, and having an earliest publication date of September 16, 2004, was, at the time the invention of U.S. Application Scrial No. 10/792,038 (the presently pending application) was made, owned by Advanced Technology Materials, Inc.

Request for Rejoinder Reminder

Applicants respectfully request rejoinder of method claims 24-31, 33-52 and 58 upon allowance of the composition claims 1-2, 4-15, 17-23, 53-57, and 59. Towards that end, withdrawn method claims 24, 38, 43-45, and 52 have been amended in a manner consistent with the pending composition claims.

Amendment to claims 1, 8, 14 and 15

Claim 1 has been amended to include the limitations of claim 7 and previously pending claims 13 and 15.

Claim 8 has been amended to include a limitation of claim 23.

Claims 14 and 15 have been amended to include limitations in claim 7.

Rejection of Claims and Traversal Thereof

In the November 24, 2006 Office Action:

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claims 8-9, 11-13, and 22 were rejected under 35 U.S.C. 102(e) as being anticipated by, or in the alternative, under 35 U.S.C. §103(a) as obvious over Minsek et al. (U.S. Patent Application Publication No. 20040180300);

claims 8-9, 11-13, and 22 were rejected under 35 U.S.C. 102(a) as being anticipated by, or in the alternative, under 35 U.S.C. §103(a) as obvious over Skee (U.S. Patent No. 6,599,370);

claims 1-2, 4-6, 10, 14-21, 23, 53-56, and 59 were rejected under 35 U.S.C. §102(a) as anticipated by, or, in the alternative under 35 U.S.C. §103(a) as being unpatentable over Skee in view of En et al. (U.S. Patent Application Publication No. 20040134682), Yokoi et al. (U.S. Patent Application Publication No. 20050106492) and Moore (U.S. Patent No. 6,551,973);

claims 1-6 were rejected under 35 U.S.C. 102(b) as being anticipated by Carati et al. (U.S. Patent No. 5,908,968); and

claims 1-5 and 10 were rejected under 35 U.S.C. 102(a) as being anticipated by Miller et al. (U.S. Patent No. 6,572,743).

These rejections are traversed and reconsideration of the patentability of the pending claims is requested in light of the following remarks.

Rejection under 35 U.S.C. §§ 102, 103 in view of Minsek

1. In the November 24, 2006 Office Action, claims 8-9, 11-13, and 22 were rejected under 35 U.S.C. 102(e) as being anticipated by, or in the alternative, under 35 U.S.C. §103(a) as obvious over Minsek et al. (U.S. Patent Application Publication No. 20040180300) (hereinafter Minsek). Applicants traverse such rejections.

Claim 8 has been amended herein to recite:

"A cleaning composition including an active cleaning combination (ACC) and dinonylphenol ethoxylate, wherein said ACC consists of a strong base in combination with an oxidant and said cleaning composition is useful for removing

photoresist and/or sacrificial anti-reflective coating (SARC) materials from a substrate having such material(s) thereon." (emphasis showing added limitation(s))

It is well established, as a matter of law, that a claim is anticipated only if each and every element as set forth in the claim is found, either expressly or inherently described, in a single prior art reference. *Verdegaal Bros. v. Union Oil Co. of California*, 2 U.S.P.Q.2d 1051, 1053 (Fed. Cir. 1987).

Minsek does not expressly or inherently disclose a composition including dinonylphenol ethoxylate. Accordingly, Minsek does not anticipate applicants' claim 8, and claims 9, 11-13 and 22 depending therefrom.

As stated hereinabove, Minsek, which qualifies as a §102(e) reference, was commonly owned by Advanced Technology Materials, Inc. at the time of filing of the present application. Consistent with the provisions of MPEP §706.02(l)(2), the statement hereinabove by applicants disqualifies U.S. Patent Application Publication No. 2004/0180300 to Minsek from being used in a rejection under 35 U.S.C. §103(a) against claims of the present application. See also, MPEP §§ 706(l)(1).

In conclusion, Minsek does not anticipate applicants' claims 8-9, 11-13, and 22 and is not available as prior art for a rejection based on obviousness. Withdrawal of the §§ 102, 103 rejections in view of Minsek is respectfully requested.

Rejection under 35 U.S.C. §§ 102, 103 in view of Skec

1. In the November 24, 2006 Office Action, claims 8-9, 11-13, and 22 were rejected under 35 U.S.C. 102(a) as being anticipated by, or in the alternative, under 35 U.S.C. §103(a) as obvious over Skee (U.S. Patent No. 6,599,370). Applicants traverse such rejection.

Skee relates to aqueous alkaline compositions useful in the microelectronics industry for stripping or cleaning semiconductor wafer substrates by removing photoresist residues and other unwanted contaminants. The Skee compositions include one or more metal ion-free bases in sufficient amounts to produce a pH of about 10-13 and at least one bath stabilizing agent. The Skee compositions may also include a suitable amphotoric, non-ionic, anionic or cationic surfactant.

As indicated hereinabove, applicants' claim 8 has been amended herein to recite a composition that includes dinonylphenol ethoxylate. Notably, Skee does recite that the surfactant may be a polyoxyethylene (POE) monoalkyl ether, however, Skee does not expressly or inherently disclose a composition including dinonylphenol ethoxylate.2

According to the MPEP §2131.02, when the compound is not specifically named . . . anticipation can only be found if the classes of substituents are sufficiently limited or well delineated. Ex parte A, 17 USPQ2d 1716 (Bd. Pat. App. & Inter. 1990).

Notably, the polyoxyethylene (POE) monoalkyl ether surfactant subgenus is rather extensive, as introduced, in part, in U.S. Patent No. 5,258,136 in the name of Smith et al. (see Abstract).3

Novel phenol compounds of the formula:



wherein R, is an alkyl substituent of from 8 to 12 carbon atoms, R is an othyl or propyl enhancem, and n is from about 50 to 200.

These compounds as well as ornain other similarly alkonylated compounds, for example, a compound of



dinonylphenol ethoxylate is represented by Formula B

wherein R2 and R3 are each, independently, an afkyl substituent of 8 to 15 carbon stoms, R is an ethyl or peopyl substituent, and u is from about 50 to 200, may be used in sodium stenzate based stick gels to enhance transparency, minimize syncresis and/or increase the serting point of the gel.

In other words, Smith et al. discloses at least 17 different POE monoalkyl ether compounds.

The POE monoalkyl ether subgenus also includes monoalkyl substituents that do not have a phenyl group, i.e., saturated or unsaturated monoalkyls such as POE caprylyl ether, POE nonyl ether, POE decyl ether, POE undecyl ether, POE lauryl ether, POE tridecyl ether, POE myristil ether, POE pentadecyl ether, POE cetyl ether, POE heptadecyl ether, POE sicaryl ether, POE

² dinonylphenol ethoxylate is synonymous with POE dinonyl phenyl ether and dinonylphenol

polyoxyethylene, which all have CAS No. 9014-93-1.

Smith et al. relates to sodium stearate cosmetic gel stick formulations and is included herein to evidence the large number of possible molecules in the POE monoalkyl ether subgenus.

oleyl ether, etc.

Turning to the present case, the polyoxyethylene monoalkyl ether subgenus is not sufficiently limited and as such, the subgenus cannot anticipate the dinonylphenol ethoxylate species. Accordingly, Skee does not anticipate applicants' claim 8, and claims 9, 11-13 and 22 depending therefrom.

With regards to obviousness, Skee does recite that the surfactant may be a polyoxyethylene monoalkyl ether (see, Skee, col. 9, lines 17-64, as reproduced hereinbelow). That said, Skee also recites no less than 40 other possible surfactant subgenus's.

Amphatesic sudictums useful in the compositions of the present invention include betances and authobetones such as alkyl betaines, andostkyl betaines, alkyl withoetaines and amidialityl sulfobutines; aminocarboxyle used derivatives such as amphoglycianous, amplitopropionates, amplitopropionates, amplitopropionates, amplitopropionates, instrudicted such as alkoxyalkyl iminodiacide er alkoxyalkyl iminodiacides; and alkylamido civides and alkylamido civides and alkylamido alkylamido civides; fluoroalkyl sulforases and fluorinated alkylamidocarbox and mixtures thereof.

Preferably, the amphoteric surfactoria are carcamidapropyl betains, coccamidapropyl dimethyl stalins, coccamidopropyl hydroxy sultains, energyleza-photilgropianate, coccamidatogropianate, ascenamphopropianate, excessphotydroxyethyl propianate, isodecylexypympylimino dipropionic acid, lassylimino dipropianate, excentidopropylamine unite and excessmine exids acri fluorinated alleyl symphoteries.

Namionic surfictants useful in the economisms of the present invention include acetylenic clods, ethnoclassed acetylenic dieds, throrinsted alkyl afteografus, fluorinated alkylessers, fluorinated polytoxycthylene alkients, aliphatic acid cosets of polytoxycthylene dieds, polytoxycthylene monalkyl ethers, polytoxycthylene dieds, alloxine type surfactants, and alkylene glycol manalkyl ethers. Perferably, the non-ienic suffactants are acutylenic dioks or ethoxylated acetylenic dioks.

Animic surfactants useful in the co-apositions of the present invention, include surfronybuses, N-accylamous/index, sulfacates, sulfaces, and mono and discuss of orthophose-phoric and surface as decyl phosphote, Proterably, the animal surfactants are metal-fixed surfactants.

Cationic surfactable assetul in the compositions of the present invention include amide ethor; here, dialkyldine-sulythmenoisen satis, dialkylmorphotion in satis, alkylten-syldinesthylaminonium satis, alkyltrinethylaminonium satis, and alkyltyridinium satis. Preferably, the cationic surfactable are halogen-free surfactable.

For applicants' claim 8 to be non-obvious in view of Skee, there has to be some motivation, teaching or suggestion in Skee to (a) select the non-ionic surfactant from a list of four broad surfactant genus's, (b) select the subgenus polyoxyethylene monoalkyl ethers from the extensive list of other non-ionic surfactants, and thereafter (c) select polyoxyethylene dinonyl phenyl ether from a list of no less than 30 possible polyoxyethylene monoalkyl ethers.⁴

acetylenic diols ethoxylated acetylenic diols fluorinated alkyl alkoxylates fluorinated alkylesters at least 30 possible amphoteric fluorinated polyoxyethylene alkanols polyoxyethylene monoalkyl aliphatic acid esters of polyhydric alcohols non-ionic ethers including polyoxyethylene monoalkyl ethers anionic POE dinonyl phenyl ether polyoxyethylene diols cationic siloxane type surfactants alkylene glycol monoalkyl ethers

According to MPEP §2144.08, entitled "Obviousness of Species When Prior Art Teaches Genus," the prior art must provide some motivation to one of ordinary skill in the art to make the claimed invention in order to support a conclusion of obviousness. See, e.g., In re Vaeck, 20 USPQ2d 1438, 1442 (Fed. Cir. 1991). In other words, to establish a prima facie case of obviousness, the Examiner must show where, in Skee, is the motivation, teaching or suggestion to select dinonylphenol ethoxylate from the surfactant genus (i.e., non-ionic), and the POE monoalkyl ether subgenus.

In conclusion, Skee does not anticipate or motivate, teach or suggest applicants' claim 8, and claims 9, 11-13 and 22 depending therefrom. Withdrawal of the §§ 102, 103 rejections in view of Skee is respectfully requested.

2. In the November 24, 2006 Office Action, claims 1-2, 4-6, 10, 14-21, 23, 53-56, and 59 were rejected under 35 U.S.C. §102(a) as anticipated by, or, in the alternative under 35 U.S.C. §103(a) as being unpatentable over Skee in view of En et al. (U.S. Patent Application Publication No. 20040134682) (hereinafter En), Yokoi et al. (U.S. Patent Application Publication No. 20050106492) (hereinafter Yokoi) and Moore (U.S. Patent No. 6,551,973). Applicants traverse such rejection.

Claim 1 has been amended to recite:

"A cleaning composition including a quaternary base, at least one alkali or alkaline earth base, and at least one additional component selected from the group consisting of a chelator, an oxirane species, and combinations thereof,

⁴ Formula A - C₈-C₁₈; Formula B - C₈-C₁₅; POA monoalkyl ethers without the phenyl group - C₈-C₂₀.

wherein said chelator comprises a species selected from the group consisting of: 1-amino-1,2,4-triazole; 1-amino-1,2,3triazole; 1-amino-5-methyl-1,2,3-triazole; 3-amino-1,2,4-3-mercapto-1,2,4-triazole; 3-isopropyl-1,2,4triazole; triazole; naphthotriazole; 2-mercaptobenzoimidazole; mercaptobenzothiazole; 5-aminotetrazole; 5-amino-1,3,4-2,4-diamino-(-methyl-1,3,5-triazine; thiadiazole-2-thiol; 1,3-dimethyl-2methyltetrazole; triazine; imidazolidinone; 1,5-pentamethylenetetrazole; 1-phenyl-5diaminomethyltriazine; mercaptotetrazole; mercaptobenzothiazole; imidazoline thione; 4-methyl-4H-5-amino-1,3,4-thiadiazole-2-thiol; 1,2,4-triazole-3-thiol; benzothiazole; tritolyl phosphate; indiazole; adenine; iminodiacetic salicylamide; thioglycerol; benzoguanamine; melamine; thiocyranuric acid; anthranilic acid; 3-mercaptopropanol; and combinations thereof, and said cleaning composition is useful for removing photoresist and/or sacrificial anti-reflective coating (SARC) materials from a substrate having such material(s) thereon." (emphasis showing added limitation(s))

Skee does not expressly or inherently disclose the use of an oxirane species and/or the specifically enumerated chelators. According, Skee does not anticipate applicants' claim 1 or claims depending therefrom. Withdrawal of the rejection of claims 1-2, 4-6, 10, 14-21, 23, 53-56, and 59 as being anticipated by Skee is respectfully requested.

With regards to obviousness, there is no motivation, teaching or suggestion in Skee to include the oxirane species and/or the specifically enumerated chelators. Accordingly, two of the requirements needed to establish a *prima facie* case of obviousness have not been met.⁵ The Examiner is respectfully reminded that in order to make a legally sufficient rejection under 35 U.S.C. §103(a) based on a modification of a reference disclosure, the Examiner <u>must explain with specificity what areas of the reference suggest the modification</u>. Ex parte Humphreys, 24 U.S.P.Q.2d 1255, 1262 (B.P.A.I. 1992).

The inclusion of En, Yokoi and Moore does not cure the deficiency of Skee for the following reasons.

En relates to a process for manufacturing multilayer printed circuit boards. The only teaching

⁵ Specifically, there must be some suggestion or motivation, either in the references themselves or in the knowledge generally available to one of ordinary skill in the art, to modify the reference teachings, and the prior art reference must teach or suggest all the claim limitations

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relating to chelating agents in En is at paragraphs [0248]-[0256] whereby a copper surface is roughened using a <u>cupric azole</u> complex and an organic acid. It is noted that En does not motivate, teach or suggest applicants' oxirane species and/or specifically enumerated chelators.

There can be no motivation, teaching or suggestion to combine Skee and the chelating agent teaching in En because Skee would be rendered unsatisfactory for its intended purpose. As such, a *prima facie* case of obviousness does not exist. See *In re Gordon*, 733 F.2d 900, 221 USPQ 1125 (Fed. Cir. 1984).

As indicated, the lone teaching in En relating to the use of chelators relates to a composition for etchingly roughening a copper surface (as indicated in the chemical reactions provided in paragraph [0250] of En). In contrast, the method of Skee is described as removing "unwanted metallic and organic contaminants but does not cause unacceptable corrosion to . . . copper, film" (see Skee, col. 13, lines 33-38). These are mutually exclusive teachings – Skee doesn't want the copper etched during cleaning while En is purposely removing copper. Clearly the combination of Skee and En would render Skee unsatisfactory for its intended purpose and as such, there can be no motivation or suggestion to combine Skee and En.

With regards to Yokoi, Yokoi relates to a photoresist stripping solution having a pH value of 3.5 to 5.5. As a reminder, Skee relates to a composition having a pH in a range from 10-13. Importantly, Yokoi recites that stripping solutions having an alkaline pH "cannot sufficiently protect Cu-based metal wirings from corrosion." In other words, Yokoi actually teaches away from the combination with Skee. It is improper to combine references where the references teach away from their combination. See, e.g., In re Grasselli, 218 U.S.P.Q. 769, 779 (Fed. Cir. 1983).

Further, following the combination of Skee and Yokoi, as proposed by the Examiner, what should be the pH of the final solution - acidic or basic? These are mutually exclusive pH regions. Importantly, the Examiner is reminded that cherry picking the disclosures of Skee and Yokoi in an attempt to re-create applicants' claimed invention is not allowed. Anything else would amount to hindsight reconstruction, which the courts have made clear is improper.

Accordingly, there is no objective motivation, teaching or suggestion to combine Skee and Yokoi as proposed by the Examiner.

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With regards to Moore, Moore teaches several corrosion inhibitors and chelating agents, including benzotriazoles and tolyltriazole, however, Moore does not cure the deficiencies of Skee. Specifically, Moore, and hence the combination of Skee and Moore, does not motivate,

teach or suggest oxirane species and/or applicants' specifically enumerated chelators.

Accordingly, two of the requirements needed to establish a prima facie case of obviousness have

not been met.

In conclusion, Skee and the combination of Skee with En, Yokoi and Moore does not make

obvious applicants' claim 1 and claims 2, 4-6, 10, 14-21, 23, 53-56, and 59 depending therefrom.

Withdrawal of the rejection under §103 is respectfully requested.

Rejection under §102 in view of Carati

In the November 24, 2006 Office Action, claims 1-6 were rejected under 35 U.S.C. 102(b) as

being anticipated by Carati et al. (U.S. Patent No. 5,908,968) (hereinafter Carati). Applicants

traverse such rejection.

Carati relates to a process for the hydroisomerization of n-paraffins in the presence of a

difunctional catalyst. Importantly, Carati does not relate in any way to the removal of photoresist

or SARC materials from a substrate, as claimed by applicants herein.

Carati does disclose a composition including at least NaOH, tetraethylammonium hydroxide and

boric acid, which is combined which other ingredients to produce a solid catalyst. That said,

Carati does not expressly or inherently teach the use of applicants' oxirane species and/or the

specifically enumerated chelators. According, Carati does not anticipate applicants' claim 1 or

claims depending therefrom. Withdrawal of the rejection of claims 1-6 as being anticipated by

Carati is respectfully requested.

Rejection under §102 in view of Miller

In the November 24, 2006 Office Action, claims 1-5 and 10 were rejected under 35 U.S.C. 102(a)

as being anticipated by Miller et al. (U.S. Patent No. 6,572,743) (hereinafter Miller). Applicants

traverse said rejection.

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Miller relates to an electrode assembly for electroplating conducting portions of nonconductors. Importantly, Miller does not relate in any way to the removal of photoresist or SARC materials

from a substrate, as claimed by applicants herein.

Miller does teach a composition including KOH and ammonium hydroxide, however, Miller does not expressly or inherently teach the use of applicants' oxirane species and/or the specifically enumerated chelators. According, Miller does not anticipate applicants' claim 1 or claims depending therefrom. Withdrawal of the rejection of claims 1-5 and 10 as being anticipated by

Miller is respectfully requested.

Conclusion

Claims 1, 2, 4-15, 17-23, 53-57 and 59 are in form and condition for allowance. If any additional issues remain, the Examiner is requested to contact the undersigned attorney at (919) 286-8090 to discuss same. Authorization is hereby given to charge any deficiency in applicable fees for this response to Deposit Account Number 13-4365 of Moore & Van Allen PLLC.

Respectfully submitted,

MOORE & VAN ALLEN PLLC

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